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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
09/774,921	01/31/2001	Hideaki Shiraishi	14274	5315
23389	89 7590 04/12/2004		EXAMINER	
SCULLY SCOTT MURPHY & PRESSER, PC 400 GARDEN CITY PLAZA GARDEN CITY, NY 11530			NGUYEN, DUNG T	
			ART UNIT	PAPER NUMBER
·			2871	
			DATE MAILED: 04/12/2004	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)			
	09/774,921	SHIRAISHI, HIDEAKI			
Office Action Summary	Examiner	Art Unit			
	Dung Nguyen	2871			
The MAILING DATE of this communication appe Period for Reply	ars on the cover sheet with the c	orrespondence address			
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. Extensions of time may be available under the provisions of 37 CFR 1.136 after SIX (6) MONTHS from the mailing date of this communication. If the period for reply specified above, is less than thirty (30) days, a reply of If NO period for reply is specified above, the maximum statutory period will. Failure to reply within the set or extended period for reply will, by statute, of Any reply received by the Office later than three months after the mailing of earned patent term adjustment. See 37 CFR 1.704(b).	(a). In no event, however, may a reply be time within the statutory minimum of thirty (30) days apply and will expire SIX (6) MONTHS from ause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).			
Status					
1) Responsive to communication(s) filed on 05 Ma	rch 2004.				
2a) ☐ This action is FINAL. 2b) ☑ This a					
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims					
4) ☐ Claim(s) 1-11 is/are pending in the application. 4a) Of the above claim(s) 5-11 is/are withdrawn 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) 1-4 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and/or					
Application Papers					
9) The specification is objected to by the Examiner.	<u>-</u>				
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.					
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).					
11)☐ The oath or declaration is objected to by the Exa					
Priority under 35 U.S.C. § 119					
 12) Acknowledgment is made of a claim for foreign per a) All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the priority application from the International Bureau * See the attached detailed Office action for a list of 	have been received. have been received in Application y documents have been receiven (PCT Rule 17.2(a)).	on No ed in this National Stage			
Attachment(s)					
1) Notice of References Cited (PTO-892)	4) Interview Summary	(PTO-413)			
 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date 12/03 and 02/04. S. Patent and Trademark Office 	Paper No(s)/Mail Da				

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DETAILED ACTION

Continued Examination Under 37 CFR 1.114

- 1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 03/05/2004 has been entered.
- 2. Applicant's amendment dated 03/05/2004 has been received and entered. By the amendment, claims 1-4 are still pending in the application; claims 5-11 are stand withdrawn from consideration.
- 3. Applicant's arguments with respect to claims 1 have been considered but are moot in view of the new ground(s) of rejection.

Information Disclosure Statement

4. The information disclosure statement filed 02/05/2004 fails to comply with 37 CFR 1.98(a)(2), which requires a legible copy of each U.S. and foreign patent; each publication or that portion which caused it to be listed; and all other information or that portion which caused it to be listed. It has been placed in the application file, but the information referred to therein has not been considered.

Claim Rejections - 35 USC § 103

5. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

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(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

6. Claims 1 and 3 are rejected under 35 U.S.C. 103(a) as being unpatentable over Nakahara et al., US Patent No. 6,239,855, in view of Shishido et al., JP 9-311323.

Regarding claims 1 and 3, Nakahara et al. disclose a method for manufacturing an LCD (figure 21) comprising the step of:

forming at least two-intersection scribe cracks (64) on the substrate (outer rectangular area);

a dummy seal layer (auxiliary seal 62);

.cutting the adhered substrate (col. 2, ln 56);

Although Nakahara et al. do not disclose the scribe cracks forming on the inner side of each substrate of the LCD, Shishido et al do disclose a method of forming the same in which scribe cracks (11, 24) can be formed outside or inside surface of a substrate (figure 1 and 3). Therefore, it would have been obvious to one skilled in the art at the time of the invention was made to employ a scribe crack on an inner surface of each substrate as shown by Shishido et al. in order to properly cut off LCD cells without generating a break and oblique crack in glass substrates (see abstract).

7. Claims 2 and 4 are rejected under 35 U.S.C. 103(a) as being unpatentable over Nakahara et al., US Patent No. 6,239,855, in view of Shishido et al., JP 9-311323 and/or Applicant's admitted prior art (APA), figure 5A.

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Regarding claims 2 and 4, the modification to Nakahara et al. disclose the claimed invention as described above except for the seal layer being formed on at least one scribe crack and a step of cutting the adhered substrate by irradiation of a laser. It would have been obvious to one skilled in the art at the time of the invention was made to form a seal layer on a scribe crack and to cut a substrate by irradiating laser as shown by APA's figure 5A, since it is a common practice in the art in order to obtain a highly appropriate cutting surface as well as to prevent stress on substrate via a seal layer.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Dung Nguyen whose telephone number is 571-272-2297. The examiner can normally be reached on Monday-Thursday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Robert H. Kim can be reached on 571-272-2293. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

DN 04/05/2004 Dung Nguyen
Primary Examiner
Art Unit 2871